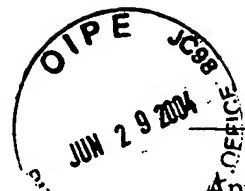


IFW



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s): HIMI et al.

Application No.: 10/656,326

Filed: September 8, 2003

Title: SEMICONDUCTOR DEVICE AND  
METHOD FOR MANUFACTURING  
THE SAME

Attorney Docket No.: 01-463

Group Art Unit: 2811

Examiner: NGUYEN, Cuong Quang

Commissioner for Patents  
Arlington VA 22202

June 29, 2004

**RESPONSE TO RESTRICTION REQUIREMENT**

Sir:

In response to a Restriction Requirement mailed on June 1, 2004 in connection with the above application, Applicant hereby elects Invention II (claims 14 – 37, drawn to a method of making a semiconductor device) without traverse.

Examination of the present application in view of the above election is respectfully requested.

Please charge any necessary fees to Deposit Account 50-1147.

Respectfully submitted,

David G. Posz  
Reg. No. 37,701

DGP/yfm  
Posz & Bethards, PLC  
11250 Roger Bacon Drive  
Suite 10  
Reston, VA 20190  
Phone: (703) 707-9110  
Customer No. 23400